

## Publication Policy for the Pathway Studio® Product

Ariadne provides this publication policy to encourage publication and to explain the conditions under which Licensed Users may publish from Pathway Studio without requiring special approval by Ariadne.

### Definitions

- **Pathway Studio Product:** Software, ResNet Database and Other Data provided by Ariadne for use or evaluation by you and your company.
- **Pathway Studio Software:** Software and data required to execute the Pathway Studio application.
- **ResNet Database®:** One or more data components of the Pathway Studio Product provided by Ariadne to Licensed Users for use with the Pathway Studio Software.
- **Other Data:** User manuals, tutorials, support information, ancillary data files provided with the Pathway Studio Software, information downloaded from the Ariadne web site.
- **Licensed Users:** Users with a valid License for the Pathway Studio Product.
- **Results:** Screen images, data extracted from tables, exported data, graphics appearing in the Pathway Studio Product produced through a substantive transformative process within the Pathway Studio product.
- **Publish:** To prepare Results and issue for distribution, whether in printed or electronic format.
- **Author:** An originator, creator, or significant contributor to a book, article, or an electronic document or system such as a web site.

### Grant of Permission

Under the Terms of the End-User License Agreement, Ariadne grants Licensed Users permission to Publish Results from their use of the Pathway Studio Product as defined above, subject to the following Limitations.

### Limitations

- 1) This agreement does not grant a license to Publish to Users participating in Ariadne “Free Trial” program or other non-paid promotional programs.
- 2) Within a single calendar year, Licensed Users are not permitted to publish more than 500 lines exported data from the Pathway Studio Product without prior approval from Ariadne.
- 3) Publication of data extracted from the ResNet Database bypassing the Pathway Studio Software, including, but not limited to reverse engineering, is expressly forbidden without written approval from Ariadne.
- 4) Users must acknowledge the Pathway Studio Product as the source of information in publication references. The name “Pathway Studio,” must be followed by the trademark registration symbol ® and a reference to the mark owner in the following form: “Ariadne Genomics, Inc, Rockville, MD, USA.”
- 5) The Author must clearly note their identity in publications. Any publication from the Pathway Studio Product which fails to clearly identify the Author is not permitted.
- 6) The copyright law of the United States ([Title 17, United States Code](#)) does not allow us to grant permission to publish materials we do not own, and puts the burden on the publisher to identify the copyright holder and obtain permission. We do not hold copyright for all data contained in the Pathway Studio Product for which the author has not specifically given copyright to Ariadne. It is the responsibility of the publisher to determine the holder of copyright and pursue the copyright owner or his or her heirs for permission to publish if Ariadne does not hold the copyright.
- 7) Approval is required to publish any information provided by Ariadne but not explicitly noted in the grant of permission above, including but not limited to Manuals, Tutorials, information downloaded from the

Ariadne website, textural or numeric information included on the Pathway Studio Software distribution media.

**Approval**

For explicit approval to publish, write to Natalia Alexandrova, Marketing Director, Ariadne Genomics, Inc. Please submit requests by regular mail (9430 Key West Ave. Rockville, MD 20850) or FAX (240-453-9026) or by email, at [info@ariadnegenomics.com](mailto:info@ariadnegenomics.com), Please be as specific as possible about what information you would like permission to publish.